## **Supporting Information**

## Chemical Management for Colourful, Efficient, and Stable Inorganic-Organic Hybrid Nanostructured Solar Cells

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## **Experimental Section**

Solar cell fabrication. A 60-nm-thick dense blocking TiO<sub>2</sub> (bl-TiO<sub>2</sub>) was deposited onto a Fdoped SnO<sub>2</sub> (FTO, Pilkington, TEC8) substrate by a spray pyrolysis deposition with a 20 mM titanium diisopropoxide bis(acetylacetonate) (Aldrich) solution at 450 °C to prevent direct contact between FTO and the hole-conducting layer. A 600-nm-thick mesoporous TiO<sub>2</sub> (mp-TiO<sub>2</sub>) films were screen-printed onto the bl-TiO<sub>2</sub>/FTO substrate using the paste, which was prepared according to a reported method,<sup>1</sup> and the films were calcined at 500 °C for 1 h to remove the organic part. The films were then immersed in a 40 mM TiCl<sub>4</sub> aqueous solution at 60 °C for 1 h and then were heat-treated at 500 °C for 30 min to improve interfacial contact with the nanocrystalline TiO<sub>2</sub>. CH<sub>3</sub>NH<sub>3</sub>I and CH<sub>3</sub>NH<sub>3</sub>Br were synthesized from 30 mL hydroiodic acid (57% in water, Aldrich) or 44 mL hydrobromide acid (48% in water, Aldrich), respectively, by reacting 27.86 mL methylamine (40% in methanol, Junsei Chemical Co., Ltd.) in a 250-mL round-bottomed flask at 0 °C for 2 h with stirring. The precipitates were recovered by evaporation at 50 °C for 1 h. The products were dissolved in ethanol, recrystallized from diethyl ether, and finally dried at 60 °C in a vacuum oven for 24 h. The CH<sub>3</sub>NH<sub>3</sub>PbI<sub>3</sub> solution of 40 wt% was made by reacting the synthesized CH<sub>3</sub>NH<sub>3</sub>I powder and PbI<sub>2</sub> (Aldrich) at a 1:1 mol ratio in γ-butyrolactone at 60 °C for 12 h. The CH<sub>3</sub>NH<sub>3</sub>PbBr<sub>3</sub> solution of 28.5 wt% was made by reacting the synthesized CH<sub>3</sub>NH<sub>3</sub>Br powder and PbBr<sub>2</sub> (Aldrich) at a 1:1 mol ratio in dimethylformamide at 60 °C for 12 h. The desired  $CH_3NH_3Pb(I_{1-x}Br_x)_3$  solutions were made by stoichiometric mixing of synthesized

CH<sub>3</sub>NH<sub>3</sub>PbI<sub>3</sub> and CH<sub>3</sub>NH<sub>3</sub>PbBr<sub>3</sub> solutions at 60 °C for 1 h. The CH<sub>3</sub>NH<sub>3</sub>Pb(I<sub>1-x</sub>Br<sub>x</sub>)<sub>3</sub> solution was then coated onto the mp-TiO<sub>2</sub>/bl-TiO<sub>2</sub>/FTO substrate by consecutive spin coating at 2000 rpm for 60 s and at 3000 rpm for 60 s and then dried on a hot plate at 100 °C for 5 min. A poly-triarylamine (PTAA) (EM index, Mw = 17,500 g/mol)/toluene (15 mg/1ml) solution with an additive of 13.6 µl Li-bis(trifluoromethanesulfonyl) imide (Li-TFSI)/acetonitrile (28.3 mg/1 ml) and 6.8 µl 4-*tert*-butylpyridine (TBP) was spin-coated on CH<sub>3</sub>NH<sub>3</sub>PbI<sub>3</sub>/mp-TiO<sub>2</sub>/bl-TiO<sub>2</sub>/FTO substrate at 3000 rpm for 30 s. Finally, an Au counterelectrode was deposited by thermal evaporation. The active area was fixed at 0.16 cm<sup>2</sup>.

**Materials characterization.** The morphology of the mp-TiO<sub>2</sub>/CH<sub>3</sub>NH<sub>3</sub>PbI<sub>3</sub> bilayer nanocomposites was observed with a field-emission scanning electron microscopy (FESEM, Tescan Mira 3 LMU FEG). The structure analysis of CH<sub>3</sub>NH<sub>3</sub>Pb(I<sub>1-x</sub>Br<sub>x</sub>)<sub>3</sub> deposited on mp-TiO<sub>2</sub> was conducted by X-ray diffraction (XRD, Rigaku D/Max II X-ray diffractometer) using Cu K $\alpha$  radiation ( $\lambda$ =0.1542 nm). The absorption spectra of the mp-TiO<sub>2</sub>/CH<sub>3</sub>NH<sub>3</sub>PbI<sub>3</sub> bilayer nanocomposites were measured using a UV-Vis spectrometer (Hitachi U-3300) with an integrated sphere.

**Device characterization.** The IPCE was measured by a power source (Newport 300W Xenon lamp, 66920) with a monochromator (Newport Cornerstone 260) and a multimeter (Keithley 2001). The current density-voltage (*J-V*) curves were measured by a solar simulator (Newport, Oriel Class A, 91195A) with a source meter (Keithley 2420) at 100 mA cm<sup>-2</sup> illumination AM 1.5G and a calibrated Si-reference cell certificated by NREL. The *J-V* curves of all devices were measured by masking the active area with a metal mask of 0.096 cm<sup>2</sup>.

## Reference

Chang, J. A.; Rhee, J. H.; Im, S. H.; Lee, Y. H.; Kim, H.; Seok, S. I.; Nazeeruddin, Md. K.; Grätzel, M. *Nano Lett.* **2010**, *10*, 2609–2612.



**Figure S1.** XRD patterns of MAPbI<sub>3</sub> (black line) and MAPbBr<sub>3</sub> (red line) deposited on mp-TiO<sub>2</sub>/FTO glass substrate. (*hkl*)t and Br(*hkl*)c indicate diffraction peak for (*hkl*) plane of tetragonal MAPbI<sub>3</sub> and cubic MAPbBr<sub>3</sub>, respectively.



Figure S2. XRD patterns of MAPb( $I_{1-x}Br_x$ )<sub>3</sub> (x = 0, 0.06, and 0.20) deposited on mp-

TiO<sub>2</sub>/FTO glass substrate after exposure to 55% humidity for 1 day. The peak around 12.5° at x=0 and 0.06 appeared after the exposure which is indexed by (001) peak of PbI<sub>2</sub>. I(*hkl*) and Br(*hkl*) indicate diffraction peak for (*hkl*) plane of MAPbI<sub>3</sub> and MAPbBr<sub>3</sub>, respectively.



**Figure S3**. The relationship between reciprocal series resistance and short circuit current density  $(J_{sc})$  for the cells fabricated from MAPbI<sub>3</sub> and MAPb $(I_{0.9}Br_{0.1})_3$  as light harvesters. Jsc was obtained as a function of light intensity.